

Fig. 1B

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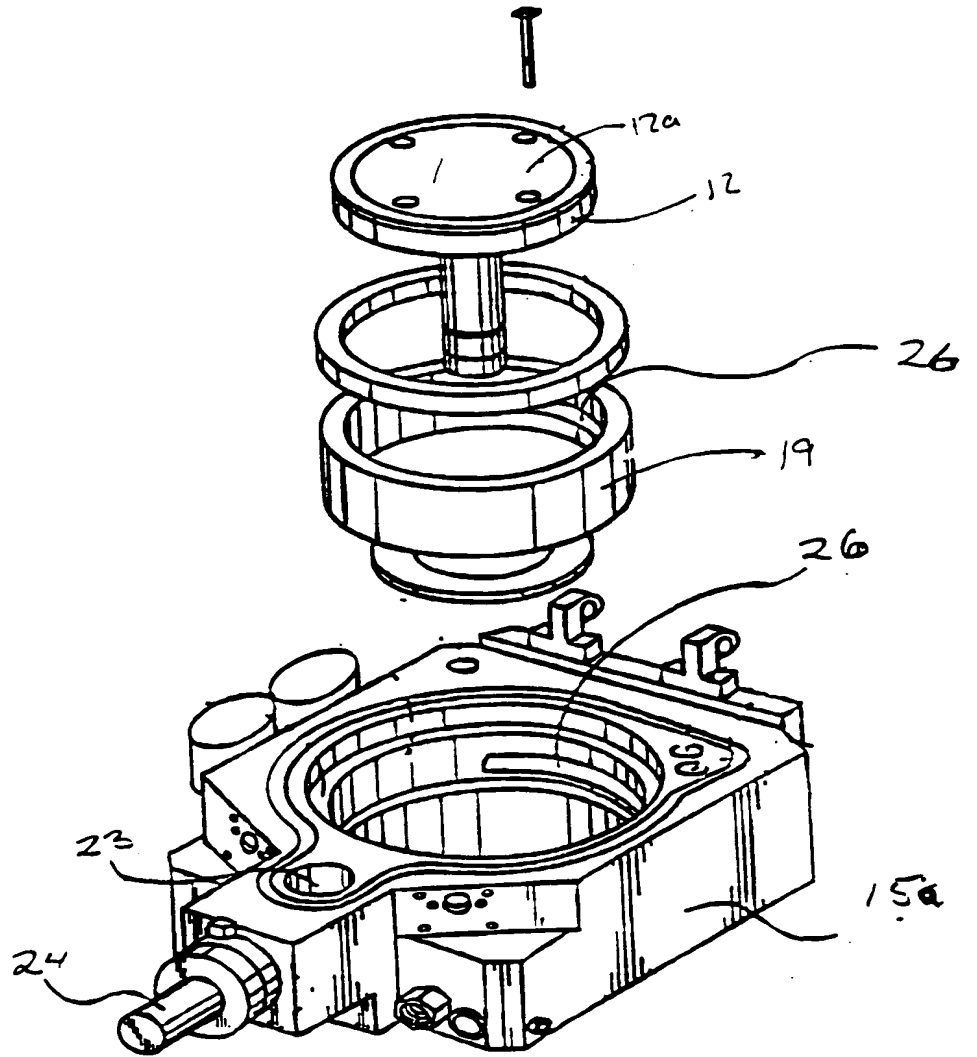
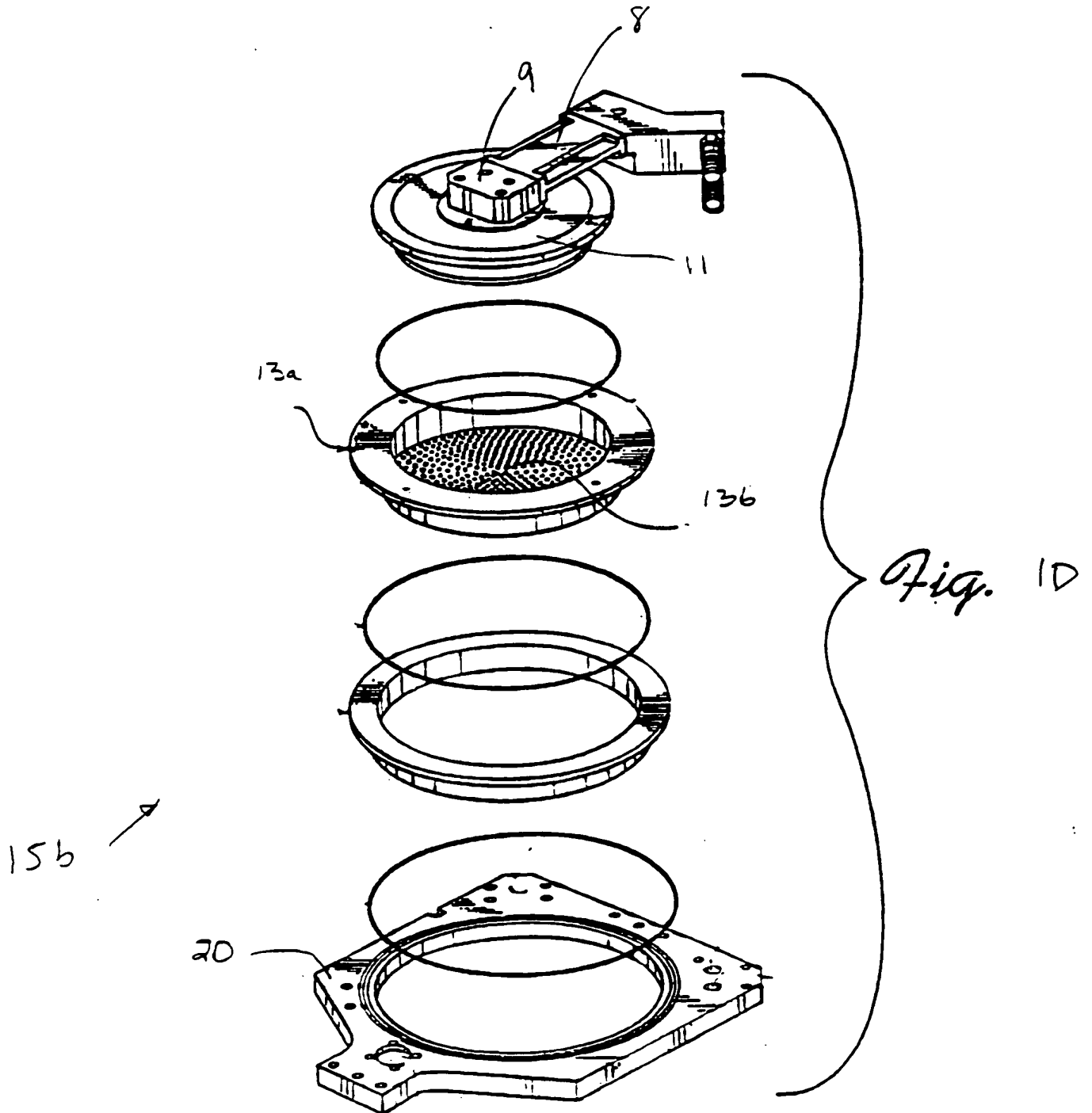


Fig. 1C

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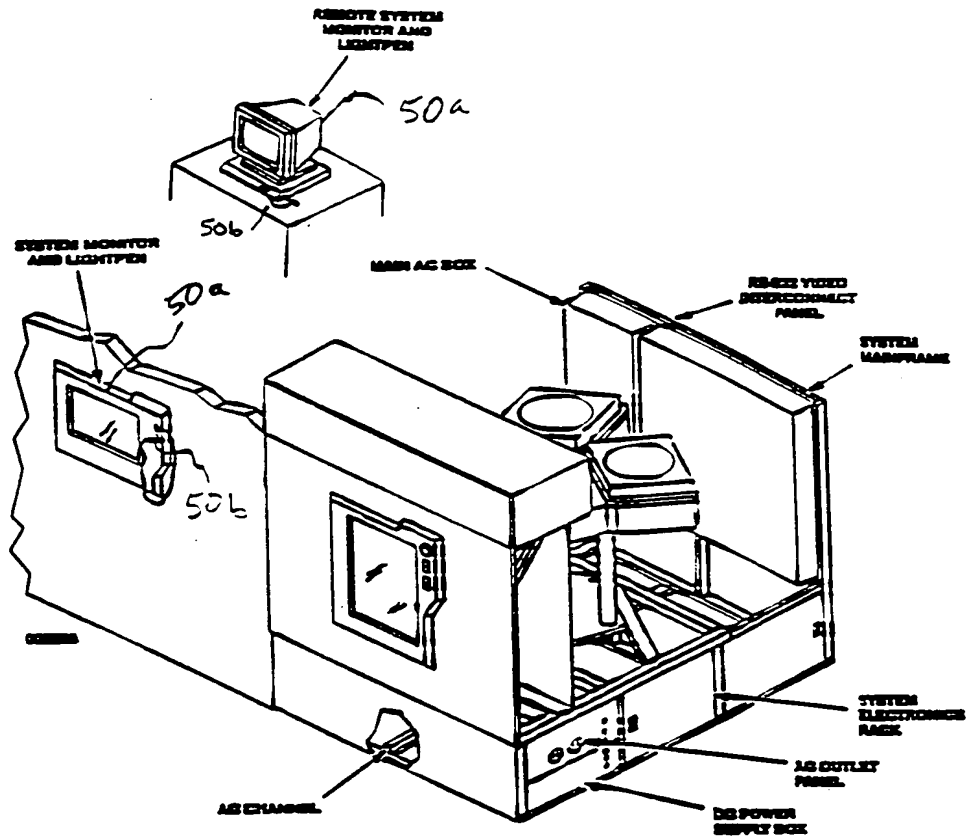
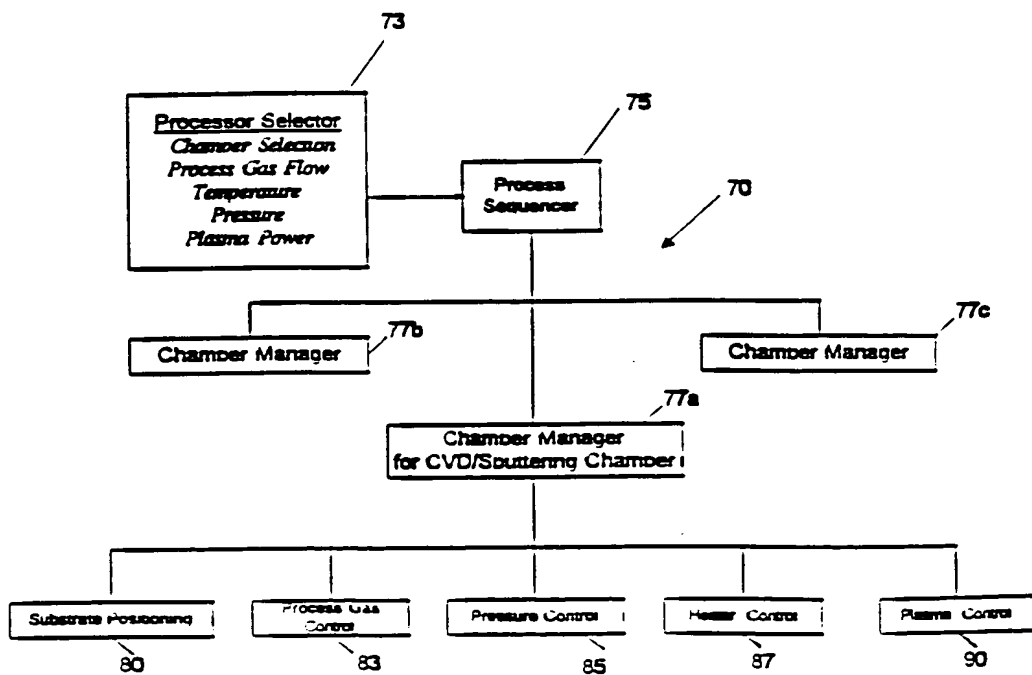


FIG. 1E



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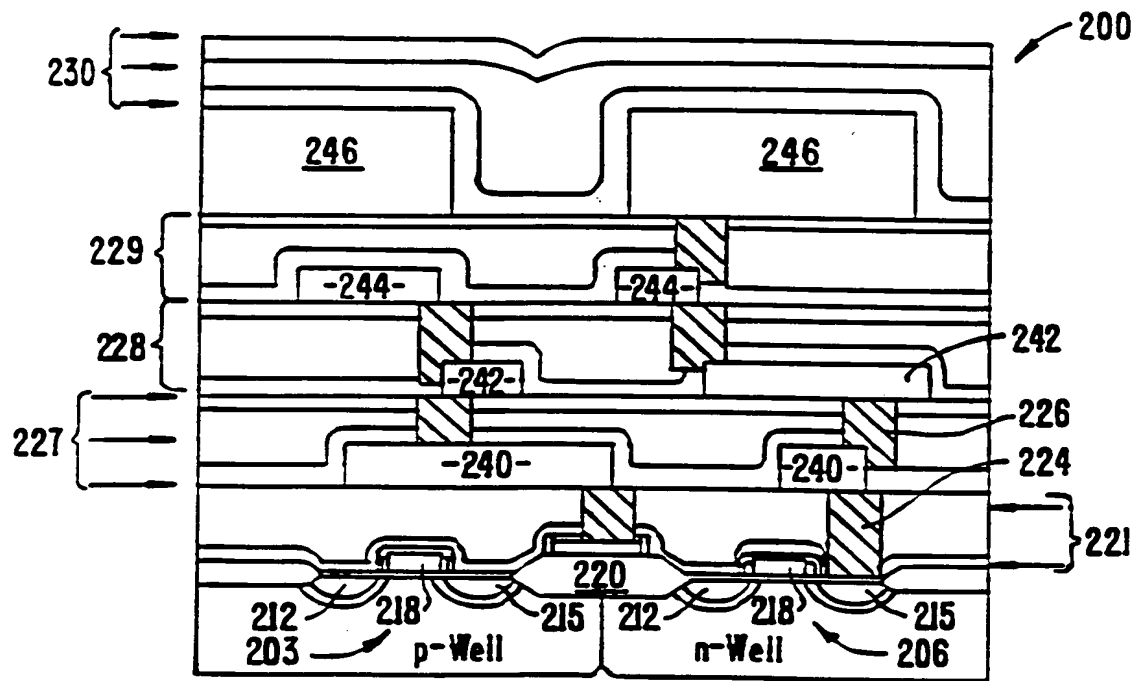


FIG. 2A

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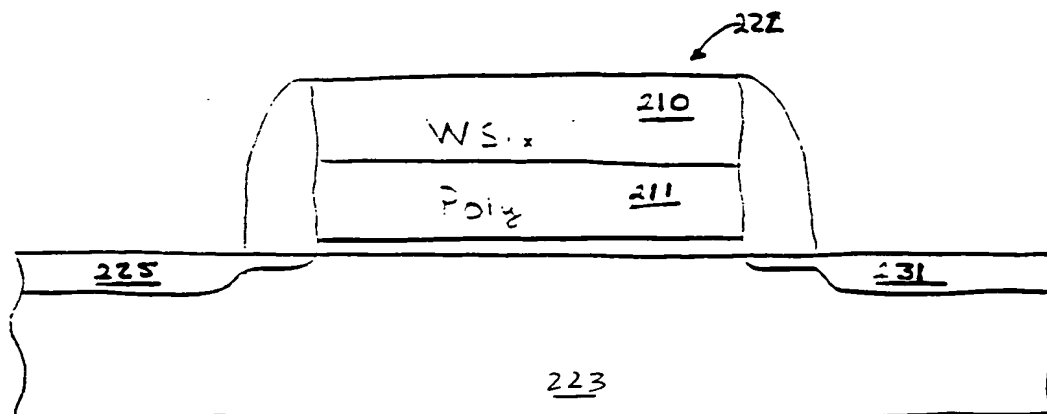


FIG. 2B

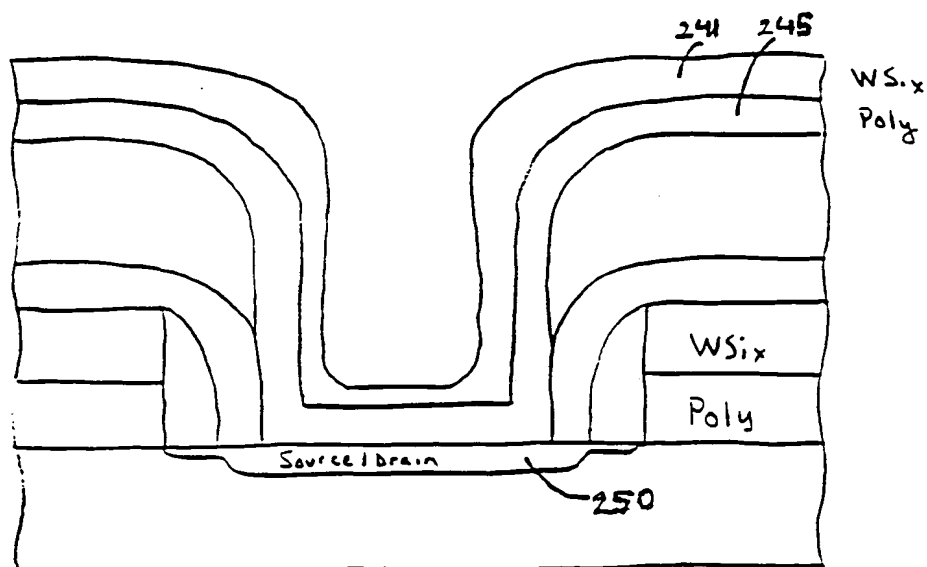


FIG. 2C

300

304

FLUORINE
SOURCE
GAS
SUPPLY

DILUENT
GAS
SUPPLY

326

324

310

308

306

MAGNETRON

ISOLATOR

AUTOTUNER

PLASMA

320

APPLICATOR

PROCESSING
CHAMBER

312

314

316

318

322

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FIG. 3

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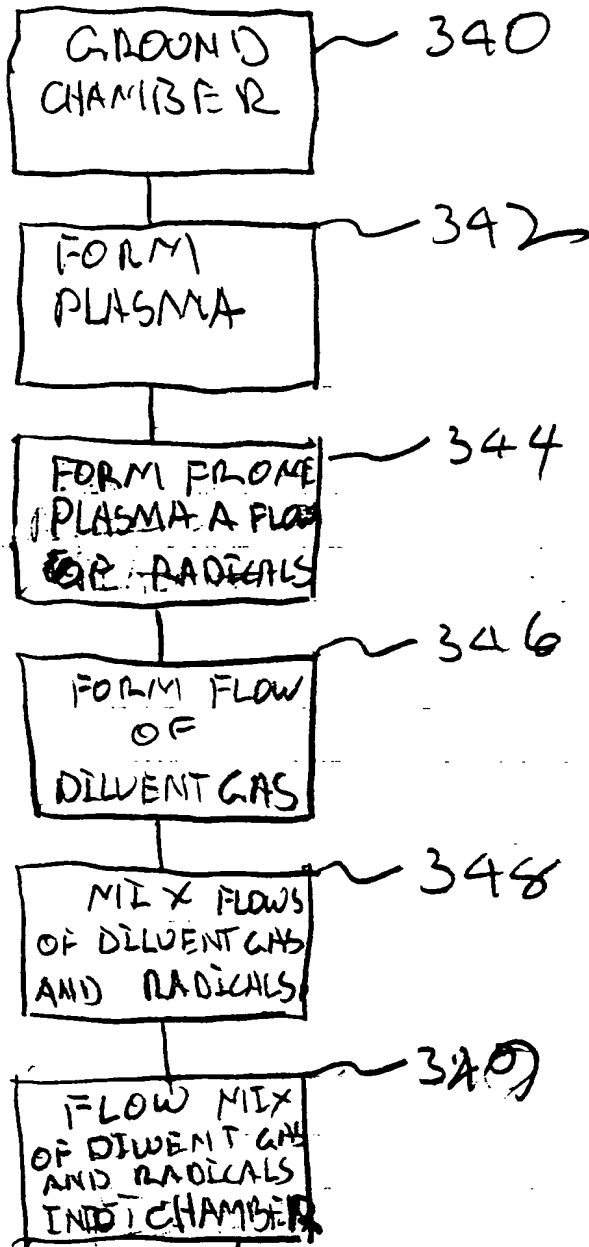


FIG. 4

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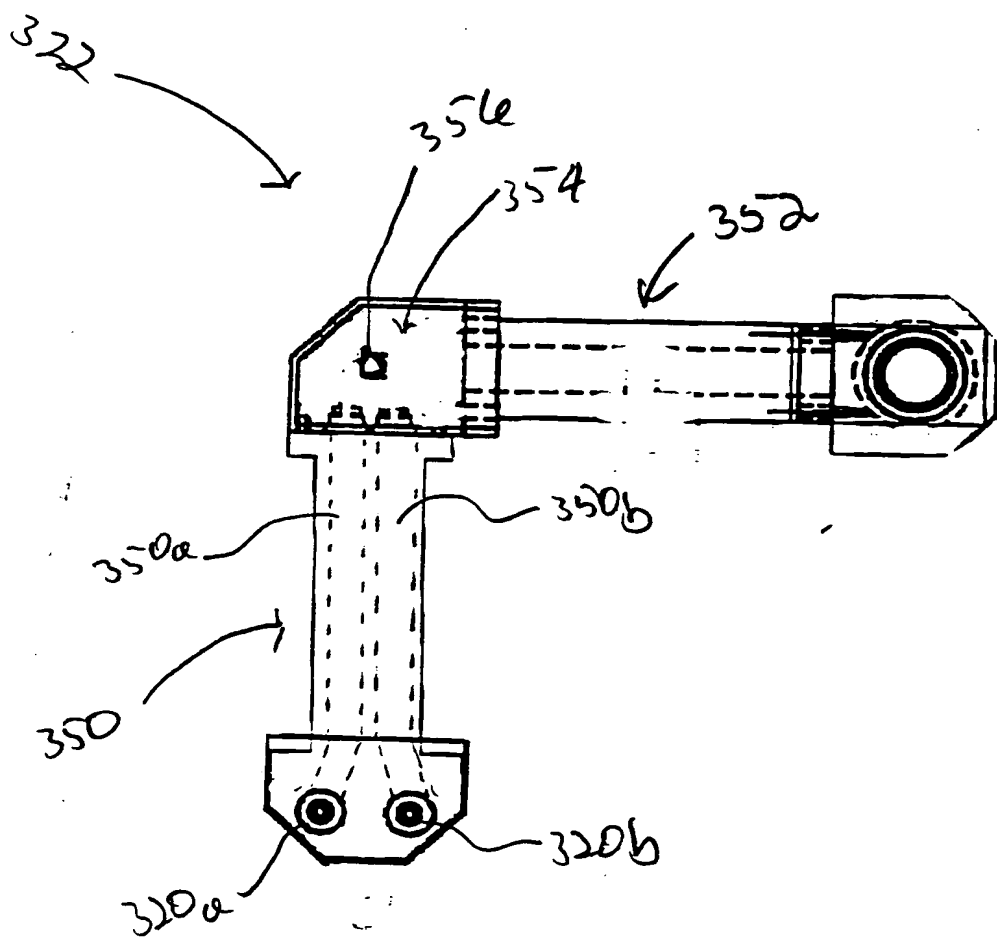
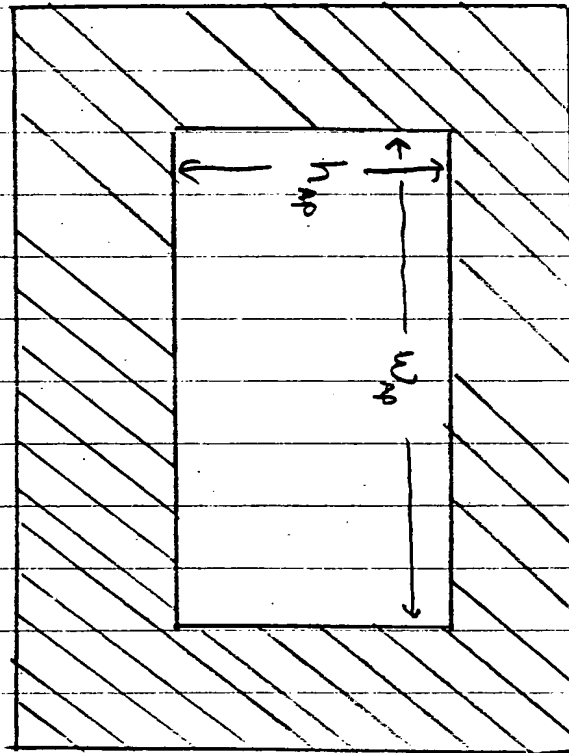


FIG. 5

[illegible]

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FIG. 7

Downloaded by [unclear] on [unclear]

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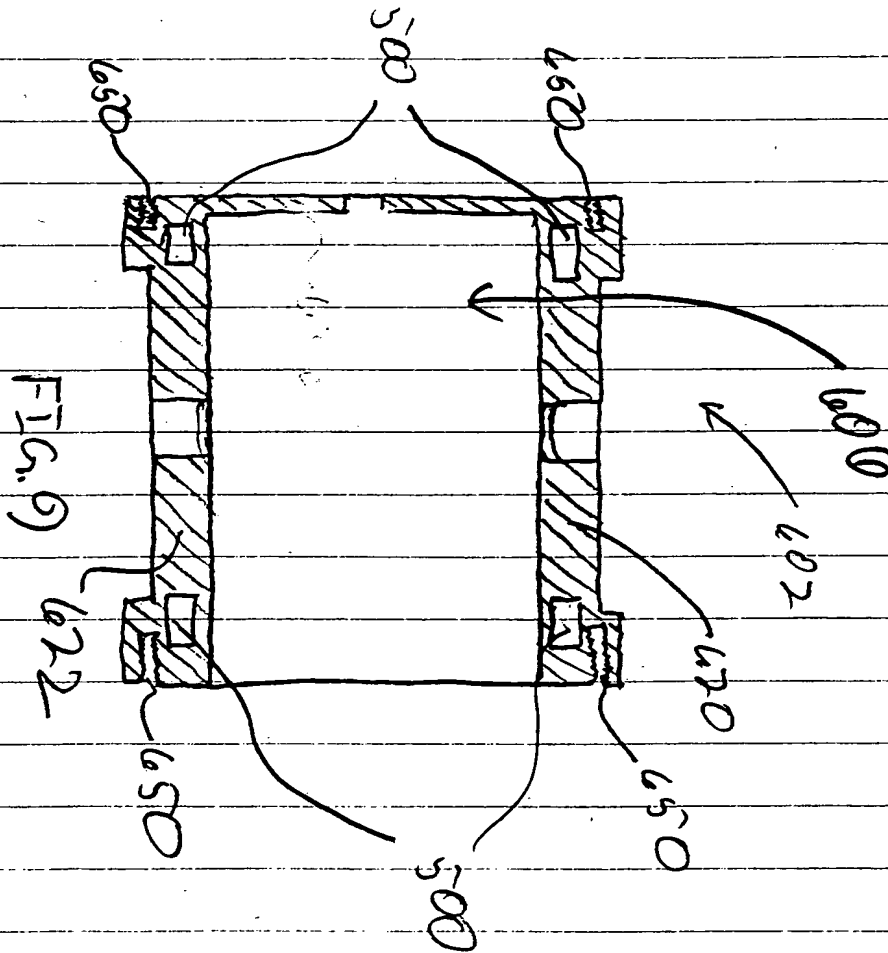


FIG. 9

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